# Semiconductor Fundamentals

Presented to EE2187 class in Semester 1 2019/20

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Lecture 11

# Course information

- Semiconductors Materials Types of Solids, Space lattice, Atomic Bonding,
- ❖ Introduction to quantum theory, Schrodinger wave equation, Electron in free space, Infinite well, and step potentials, Allowed and forbidden bands
- Electrical conduction in solids, Density of states functions, Fermi-Dirac distribution in Equilibrium,
- ❖ Valence band and Energy band models of intrinsic and extrinsic Semiconductors. Degenerate and non degenerate doping
- Thermal equilibrium carrier concentration, charge neutrality
- Carrier transport Mobility, drift, diffusion.

# Reference

#### Text Book:

- 1. Physics of Semiconductor Devices, S. M. Sze, John Wiley & Sons (1981).
- 2. Solid State Electronics by *Ben G. Streetman and Sanjay Banerjee*, Prentice Hall International, Inc.
- 3. Semiconductor Physics and Devices, Donald A. Neamen, Tata Mcgraw-Hill Publishing company Limited.
- 4. Advanced Semiconductor Fundamentals by Pirret

#### Reference Book:

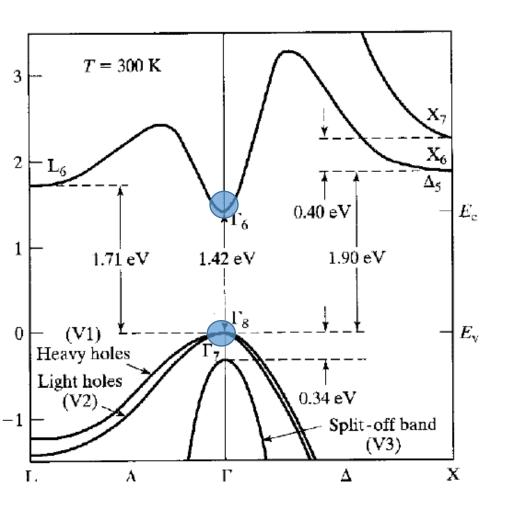
- 1. Fundamentals of Solid-State Electronic Devices, *C. T. Sah*, Allied Publisher and World Scientific, 1991.
- 2. Complete Guide to Semiconductor Devices, K. K. Ng, McGraw Hill, 1995.
- 3. Solid state physics, Ashcroft & Mermins.
- 4. Introduction to Solid State Electronics, E. F. Y. Waug, North Holland, 1980.

# Recap

$$n_o = \int_0^{E_{top}} f(E)g(E)dE$$

DOS in 3DCrystal, 
$$g(E) = \frac{m*}{2\pi^2\hbar^3} \sqrt{2m*(E - Ec)}$$

### DOS Si, Ge and GaAs

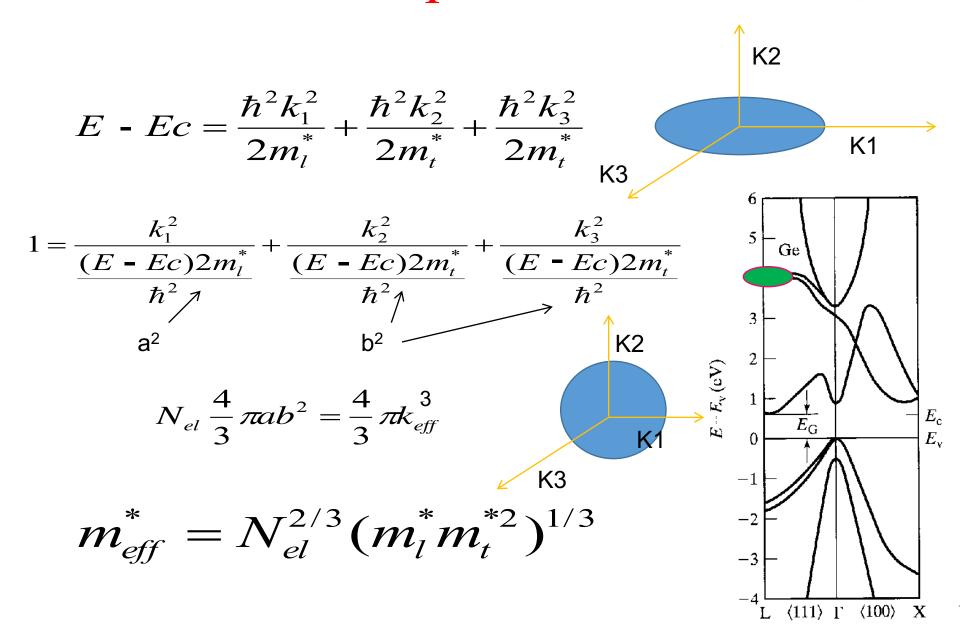


$$DOS = \frac{m*_n}{2\pi^2\hbar^3} \sqrt{2mn*(E-Ec)}$$

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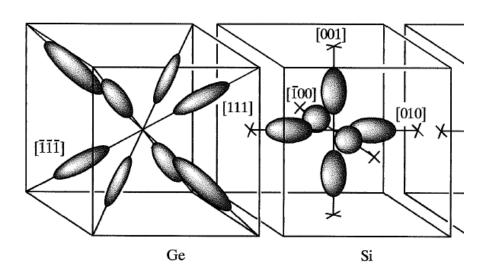
$$DOS = \frac{m*_n}{2\pi^2\hbar^3} \sqrt{2m*_{hh}(Ev - E)}$$

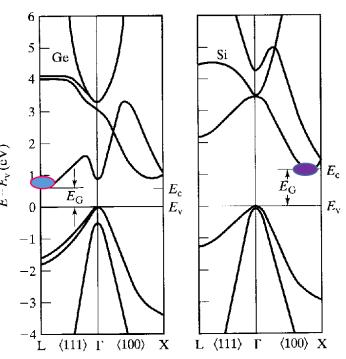
### Effective mass in ellipsoidal band i.e Si, and Ge



### Density of states for case of Ge/Si in conduction band

$$g_c(E) = \frac{m_n^{*3/2}}{\hbar^3} \sqrt{\frac{2(E - Ec)}{2}}$$





$$m_{eff}^* = 4^{2/3} (m_l^* m_t^{*2})^{1/3} for..Ge$$

$$m_{eff}^* = 6^{2/3} (m_l^* m_t^{*2})^{1/3}$$
 for .. Si

#### Density of electron/holes in energy interval dE-

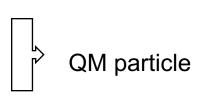
$$n_o = \int_0^{E_{top}} f(E)g(E)dE$$

f(E) can obey MB distribution if electron behave as classical particle.

i.e. ~Ae-E/kT

But Electron don't obey MB distribution as it is quantum particle and fermions', hence it obey Fermi Dirac distributions.

Classical MB
Fermions FD
Boson BE





# Rule for filling the electron

Pauli Principle: Only one electron per state

Total number of electrons is conserved  $N_T = \sum_i N_i$ 

$$N_T = \sum_{i} N_i$$

Total energy of the system is conserved  $E_T = \sum_i E_i N_i$ 

### Fermi- Dirac distribution function

#### When T>0

At thermal equilibrium, the electrons do not simply fill the lowest energy states first.

Fermi-Dirac statistics which gives the distribution of probability of an electron to have an energy E at temperature T

$$f_e(E) = \frac{1}{\exp\left(\frac{E - E_F}{k_b T}\right) + 1}$$

 $E_F$  is the Fermi energy and  $k_b$  is the Boltzmann constant.

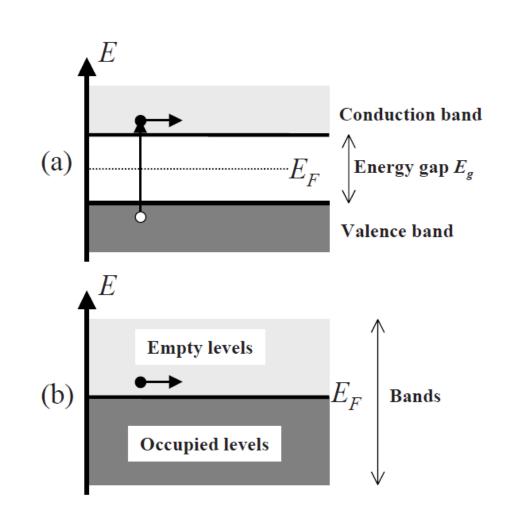
Fermi-Dirac statistics involves a chemical potential  $\mu$  instead of the Fermi energy  $E_F$ . This chemical potential depends on the temperature and any applied electrical potential. But in most cases of semiconductors, the difference between  $\mu$  and  $E_F$  is very small at the temperatures usually considered.

# Fermi Level

Assumption: solid where there are m energy levels and n electrons, and (m > n)

At equilibrium, when no electron is in an excited state (e.g. at the absolute zero temperature, 0 K), the lowest *n energy levels will be occupied* by electrons and the next remaining *m-n energy levels remain empty*.

If the highest occupied state is inside a band, the energy of this state is called the Fermi level and is denoted by  $E_F$ .



# More Insight

(1) At 
$$T = 0$$
  $K$  and  $E < E_F$ 

(a)Fermi-Dirac distribution is unity

At 
$$T = 0 K$$
 and  $E > E_F$ 

(b)Fermi-Dirac distribution [f<sub>e</sub>(E] is Zero

#### (2) At T > 0 K

(a) 
$$E=E_{F_{i}}f_{e}(E]=1/2$$

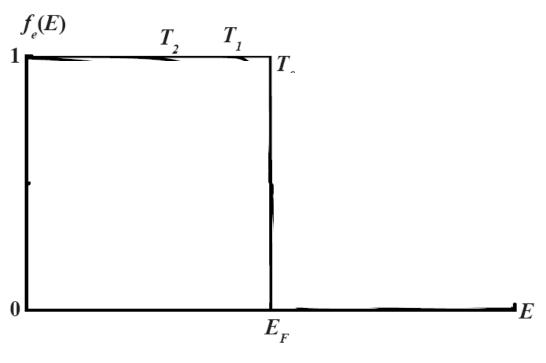
$$\exp[(E - E_E)/kT] > 1 \Rightarrow f_e(E) \approx \exp[(E - E_E)/kT]$$

Most states with energy above 3KT from E<sub>F</sub> will be empty.

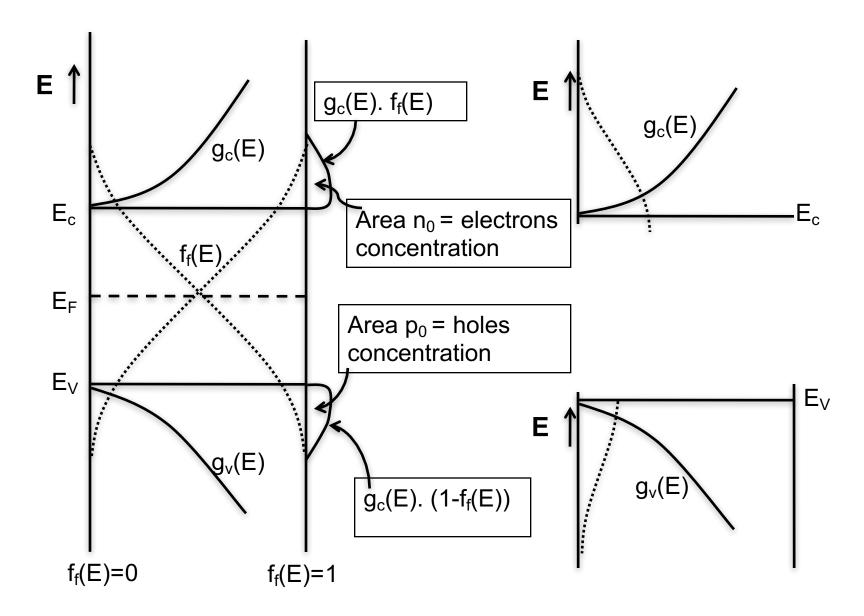
(c) EF-3KT, 
$$\exp[(E-E_F)/kT] < 1 \Rightarrow f_e(E) \approx 1 - \exp(E-E_F)/kT$$

Most states with energy below 3KT from E<sub>F</sub> will be filled.

(d) E>>3KT, beyond E<sub>f</sub> then MB and FD merged as in the case of Si



### Equilibrium Distribution of Electrons and Holes



#### Now again

$$n_o = \int\limits_{E_c}^{E_{top}} f(E)g(E)dE$$
 
$$n_o = \int\limits_{E}^{E_{top}} \frac{m_n^{*3/2}}{\hbar^3} \sqrt{(E-E_c)dE}$$
 
$$n_o = \int\limits_{E}^{E_{top}} \frac{\hbar^3}{1+\exp(E-E_E)/kT}$$
 May not be integrable

Apply MB distribution as Eg/2~16KT

$$n_o = \int_{E}^{\infty} \frac{m_n^{*3/2}}{\hbar^3} \sqrt{(E - E_c dE)} = N_c e^{-(\frac{E_c - E_f}{kT})}$$

$$N_c = 2(\frac{m_n^*kT}{\pi\hbar^2})^{3/2} \approx 10^{19}$$
 Effective density of states in CB



# Heavily Doped Si

For heavily doped the semiconductor MB distribution does not hold so, need to solve Fermi integral for solution.

e.g let us take  $n=10^{20}$ 

We get  $E_F > E_c$  which is not possible

$$n_o = \int_{E}^{\infty} \frac{m_n^{*3/2}}{\hbar^3} \sqrt{(E - E_c dE)} = N_c e^{-(\frac{E_c - E_f}{kT})}$$

so 
$$n_0 = \frac{2N_c}{\sqrt{\pi}} F_{1/2} \left( \frac{(E - E_C)}{kT} \right)$$



### Holes in Semiconductor

$$p_{o} = \int_{E_{bott}}^{E_{v}} \{(1 - f(E))\} g_{v}(E) dE$$

$$p_{o} = \int_{E}^{\infty} \frac{m_{p}^{*3/2}}{\hbar^{3}} \sqrt{(E_{v} - E dE)} = N_{v} e^{-\frac{(E_{F} - E_{v})}{kT}}$$

$$N_{v}=2(\frac{m_{v}^{*}kT}{\pi\hbar^{2}})^{3/2}$$

Since

$$m_n^* \neq m_p^*$$
 $N_c \neq N_c$ 



### Fermi Level in Intrinsic Semiconductor at Equilibrium

$$m_{n_{dos}}^* \neq m_{p_{dos}}^*$$
 $N_c \neq N_c$ 

But at Equilibrium  $n_0 = p_0$ 

$$Nc^{-\frac{(E_c-E_F)}{kT}} = N_v^{-\frac{(E_F-E_v)}{kT}}$$

$$E_F = \frac{E_C + E_V}{2} + kT \ln \frac{m_{p_{dos}}^*}{m_{n_{dos}}^*}$$

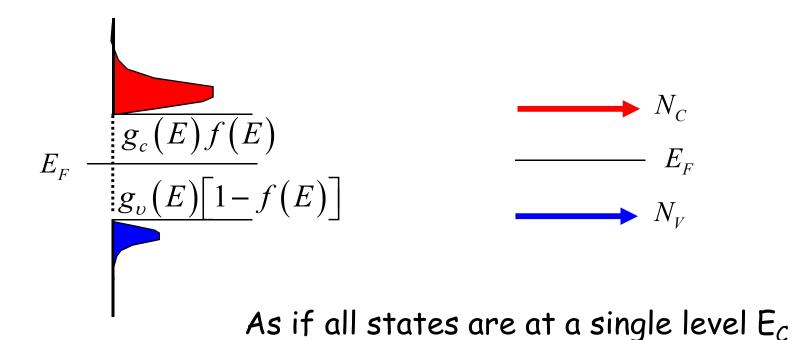
$$if, m_{p_{dos}}^* = m_{n_{dos}}^*$$

E<sub>F</sub> will be in middle of band gap



# Effective Density of States

$$n = N_C \frac{2}{\sqrt{\pi}} F_{1/2}(\eta_c) \to N_C e^{-\beta(E_c - E_F)}$$
 if  $\beta(E_c - E_F) > 3$ 





### Intrinsic carrier concentration

Product of n<sub>0</sub> and p<sub>0</sub>

$$p_o = N_v e^{-\frac{(E_F - E_v)}{kT}}$$

$$n_o = N_c e^{\frac{(E_c - E_F)}{kT}}$$

$$n_o p_o = N_v e^{\frac{(E_F - E_v)}{kT}} N_c e^{\frac{(E_c - E_F)}{kT}}$$

$$n_{o}p_{o} = N_{v}N_{c}e^{\frac{E_{c}-E_{v}}{kT}} = N_{v}N_{c}e^{\frac{E_{g}}{kT}}$$

$$n_{i}^{2} = N_{v}N_{c}e^{\frac{E_{g}}{kT}} = n_{o}p_{o}$$

Where E<sub>g</sub> is band gap, At equilibrium n<sub>o</sub>=p<sub>o</sub>=n<sub>i</sub> n<sub>i</sub> depends upon temperature and band gap

	N <sub>c</sub> (/cm <sup>3</sup> ) (10 <sup>18</sup> )	N <sub>v</sub> (/cm <sup>3</sup> ) (10 <sup>18</sup> )	$\frac{m_n^*}{m_o}$	$\frac{m_p^*}{m_o}$
Si	28	10.4	1.08	.56
Ge	10.9	6	.55	.37
GaAs	.47	7	.067	.48

	E <sub>g</sub> (eV)	Concentrat ion (/cm³) 300K	Concentrati on (/cm³) 400K
Si	1.12	1.510 <sup>10</sup>	~10 <sup>13</sup>
Ge	.72	2.4X10 <sup>13</sup>	~10 <sup>16</sup>
GaAs	1.42	1.8X10 <sup>6</sup>	-
SiC	3.5	10	100